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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/587,592	07/28/2006	Tomomi Meguro	UN110308PCTUS	2418
50488 7590 02/17/2011 ALLEMAN HALL MCCOY RUSSELL & TUTTLE LLP 806 SW BROADWAY			EXAMINER	
			TALBOT, BRIAN K	
SUITE 600 PORTLAND, OR 97205-3335			ART UNIT	PAPER NUMBER
			1715	
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			02/17/2011	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)				
	10/587,592	MEGURO ET AL.				
Office Action Summary	Examiner	Art Unit				
	Brian K. Talbot	1715				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING D - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 136(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from e, cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
2a) ☐ This action is FINAL . 2b) ☐ This 3) ☐ Since this application is in condition for allowa	 ☐ Responsive to communication(s) filed on <u>04 February 2011</u>. ☐ This action is FINAL. ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i>, 1935 C.D. 11, 453 O.G. 213. 					
Disposition of Claims						
 4) Claim(s) 1-5 and 7-11 is/are pending in the ap 4a) Of the above claim(s) is/are withdra 5) Claim(s) is/are allowed. 6) Claim(s) 1-5 and 7-11 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or 	wn from consideration.					
Application Papers						
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) accomposed applicant may not request that any objection to the Replacement drawing sheet(s) including the correction. The oath or declaration is objected to by the Examine 10.	cepted or b) objected to by the drawing(s) be held in abeyance. Section is required if the drawing(s) is objected.	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	ts have been received. ts have been received in Applicati ority documents have been receive u (PCT Rule 17.2(a)).	on No ed in this National Stage				
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s) Mail Data	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal F	ate				

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1. The amendment filed 2/4/11 has been considered and entered. Claim 6 has been canceled. Claims 1-5 and 7-11 remain in the application.

2. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Claim Rejections - 35 USC § 103

- 3. The factual inquiries set forth in Graham v. John Deere Co., 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
 - 1. Determining the scope and contents of the prior art.
 - 2. Ascertaining the differences between the prior art and the claims at issue.
 - 3. Resolving the level of ordinary skill in the pertinent art.
 - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 4. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

5. Claims 1-5 and 7-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over WO 03/021690 – translation provided by Kroll et al. (7,390,731) in combination with Vijayakumar et al. (4,851,149) in combination with Lau et al., "Growth of Epitaxial ZnO thin films by organometallic Chemical Vapor Deposition".

WO 03/021690 – translation provided by Kroll et al. (7,390,731) teaches a method of depositing an oxide layer on a substrate and a photovoltaic cell using said substrate. The photovoltaic cell includes a transparent substrate, a transparent conductive oxide, amorphous silicon, crystalline silicon and a rear contact electrode film (col. 2, lines 30-45 and Fig. 1). The conductive oxide film and/or electrode film can be zinc oxide doped with aluminum or boron. The zinc oxide can be provided by an organozinc such as diethyl zinc. An oxidizer is added such as water and the boron is added with diborane (col. 2, line 60 – col. 3, line 25). A substrate temperature of 180°C is utilized but can be in the range of 130°C-300°C and the pressure in the chamber can be from 0.01-20 mbar (pg. 3, lines 24-30).

WO 03/021690 – translation provided by Kroll et al. (7,390,731) fails to teach the use of a diluting gas such as hydrogen.

Vijayakumar et al. (4,851,149) teaches a chemical vapor deposition of zinc oxide films and products. A zinc oxide is formed by using an organozinc, water and an inert gas. The zinc oxide can be doped with a Group III element (abstract). The organozinc is dimethyl zinc (col. 2, lines 33-37). The inert gas includes argon or helium or other inert gases such as nitrogen (col. 3, lines 48-52). The Group III element can be aluminum or boron by introducing trimethyl aluminum or diborane (col. 3, lines 62-66).

Vijayakumar et al. (4,851,149) fails to teach hydrogen as the inert gas.

Lau et al., "Growth of Epitaxial ZnO thin films by organometallic Chemical Vapor Deposition" teaches using hydrogen gas as a diluting gas with the oxidizing agent in the formation of zinc oxide film doped with boron and aluminum (see above).

Therefore it would have been obvious at the time the invention was made to have modified either WO 03/021690 – translation provided by Kroll et al. (7,390,731) or Vijayakumar et al. (4,851,149) with an inert diluting gas of hydrogen as evidenced by Lau et al., "Growth of Epitaxial ZnO thin films by organometallic Chemical Vapor Deposition" with the expectation of achieving similar success and improved uniformity and surface finish.

6. Claims 1-5 and 7-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamada et al. (5,545,443) in combination with Lau et al., "Growth of Epitaxial ZnO thin films by organometallic Chemical Vapor Deposition" further in combination with Nishida (5,002,796) or vice versa.

Yamada et al. (5,545,443) teaches a method of transparent conductive zinc oxide film by incorporating a boron or aluminum containing material. Purified water is also introduced to form the oxide (abstract). The boron compound is diborane and can be diluted with hydrogen (col. 4, lines 39-50). The zinc compound is dimethyl zinc (col. 4, lines 18-22). Argon is the carrier gas.

Yamada et al. (5,545,443) fails to teach diluting the oxidizing agent with hydrogen.

Lau et al., "Growth of Epitaxial ZnO thin films by organometallic Chemical Vapor Deposition" teaches forming ZnO films by reacting diethylzinc and H_2O/H_2 , N_2O/H_2 and CO_2/H_2 oxidizing systems (abstract).

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Yamada et al. (5,545,443) in combination with Lau et al., "Growth of Epitaxial ZnO thin films by organometallic Chemical Vapor Deposition" fails to teach the photoelectric structure claimed with the transparent substrate electrode, amorphous silicon, crystalline silicon and another electrode.

Nishida (5,002,796) teaches this structure regarding a zinc oxide film using an oxygen compound and an alkyl zinc for forming photovoltaic devices (abstract). The structure is depicted in Fig. 3 and detailed in Example 4. Nishida (5,002,796) teaches applying the structure on a glass substrate, i.e. a transparent substrate. Nishida (5,002,796) teaches a substrate temperature of 200° C or between $100\text{-}450^{\circ}$ C and pressure in chamber from $1 \times 10^{-3} - 1 \times 10^{2}$ (pg. 2, lines 62-67 and pg. 6, lines 1-20)

Therefore it would have been obvious at the time the invention was made to have modified Yamada et al. (5,545,443) in combination with Lau et al., "Growth of Epitaxial ZnO thin films by organometallic Chemical Vapor Deposition" process to form the structure as depicted in Nishida (5,002,796) or to have formed the zinc oxide electrode of Nishida (5,002,796) by the method of Yamada et al. (5,545,443) with the expectation of achieving similar success.

Response to Amendment

7. Applicant's arguments with respect to claims 1-5 and 7-11 have been considered but are not found persuasive.

Applicant argued that the prior art teaches diverse coating methods and one skilled in the art would not look to combine them as the Examiner has done.

The Examiner realizes the diverse coating method of the references, but pointing out the differences between the reference and each individual reference is not sufficient to overcome a rejection based on a combination of the references. One cannot show non-obviousness by attacking references individually where the rejections are based on combinations of references. In re Keller, 208 USPQ 871 (CCPA 1981); In re Merck & Co., Inc., 231 USPQ 375 (Fed. Cir. 1986). The test of obviousness is not express suggestion of the claimed invention in any or all references but rather what the references taken collectively would suggest to those of ordinary skill in the art presumed to be familiar with them. In re Rosselet, 347 F.2d 847, 146 USPQ 183 (CCPA 1965); In re Hedges, 783 F.2d 1038. In this case the photoelectric converter is depicted in both Nishida (5,002,796) and WO 03/021690 – translation provided by Kroll et al. (7,390,731). These references fail to teach the claimed formation of the ZnO layer and this is what the secondary references are relied upon for. The combined reference teach various ways of forming the ZnO layer and one skilled in the art would have had a reasonable expectation of achieving similar success regardless of the method of application.

Applicant argued that Lau et al., "Growth of Epitaxial ZnO thin films by organometallic Chemical Vapor Deposition" teaches a higher substrate temperature and pressure than that claimed.

The Examiner agrees. However, the WO 03/021690 – translation provided by Kroll et al. (7,390,731) reference is cited for these limitations (pg. 3, lines 24-30) and not Lau et al.,

"Growth of Epitaxial ZnO thin films by organometallic Chemical Vapor Deposition" as that is cited for substituting hydrogen as a inert gas for the inert gas utilized in WO 03/021690 – translation provided by Kroll et al. (7,390,731). The same argument is addressed for the second rejection where Nishida (5,002,796) (pg. 2, lines 62-67 and pg. 6, lines 1-20) is utilized to provide the process having the claimed substrate temperature and pressures claimed. One skilled in the art would not look to change the entire deposition process and parameters with the substitution of one inert gas for another as argued by Applicant.

8. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Brian K. Talbot whose telephone number is (571) 272-1428. The examiner can normally be reached on Monday-Friday 8AM-4PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Timothy H. Meeks can be reached on (571) 272-1423. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Brian K Talbot/ Primary Examiner, Art Unit 1715

bkt